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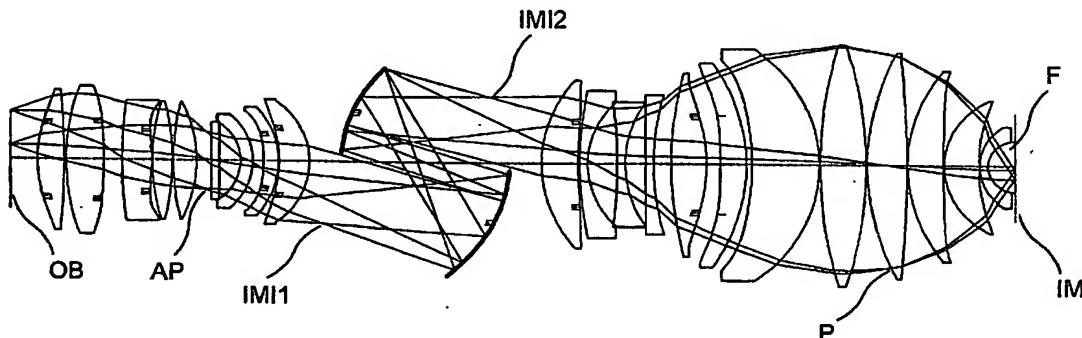
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- (71) Applicant (for all designated States except US): CARL ZEISS SMT AG [DE/DE]; Carl-Zeiss-Str. 22, 73447 Oberkochen (DE).
- (72) Inventors; and
- (75) Inventors/Applicants (for US only): SHAFER, David [US/US]; 56 Drake Lane, Fairfield, CT 06430 (US). BEDER, Susanne [DE/DE]; Brandenburger Strasse 59, 73431 Aalen (DE). SCHUSTER, Karl-Heinz [DE/DE]; Rechbergstrasse 24, 89551 Königsbronn (DE).
- (74) Agent: MÜLLER-RISSMANN, Werner; Carl Zeiss AG, Patentabteilung, 73446 Oberkochen (DE).
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(54) Title: OBJECTIVE AS A MICROLITHOGRAPHY PROJECTION OBJECTIVE WITH AT LEAST ONE LIQUID LENS



(57) Abstract: The invention relates to an objective designed as a microlithography projection objective for an operating wavelength. The objective has a greatest adjustable image-side numerical aperture NA, at least one first lens made from a solid transparent body, in particular glass or crystal, with a refractive index n_L and at least one liquid lens (F) made from a transparent liquid, with a refractive index n_F . At the operating wavelength the first lens has the greatest refractive index n_L of all solid lenses of the objective, the refractive index n_F of the at least one liquid lens (F) is bigger than the refractive index n_L of the first lens and the value of the numerical aperture NA is bigger than 1.

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